

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Sung Chul Kang, et al. )  
Serial No.: 10/750,845 ) Group Art Unit: 1752  
Filed: January 5, 2004 )  
For: PHOTORESIST COMPOSITION FOR ) Examiner: Chu, John S. Y.  
          MULTI-MICRO NOZZLE HEAD COATER )

**AMENDMENT AND RESPONSE**

**VIA EFS**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This Amendment and Response is in response to the Office Action dated April 17, 2007. Please amend the application as follows: